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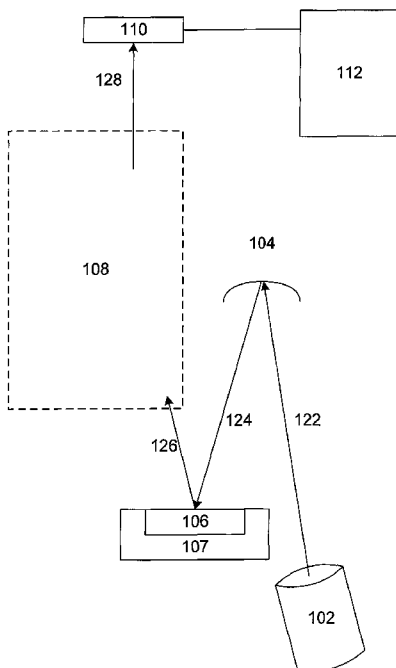
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[Continued on next page]

(54) Title: APPARATUS FOR EUV IMAGING AND METHODS OF USING SAME



(57) Abstract: One embodiment relates to an apparatus that includes an illumination source (102) for illuminating a target substrate (106), objective optics (108) for projecting the EUV light which is reflected from the target substrate, and a sensor (110) for detecting the projected EUV light. The objective optics includes a first mirror (202,302, or 402) which is arranged to receive and reflect the EUV light which is reflected from the target substrate, a second mirror (204, 304, or 404) which is arranged to receive and reflect the EUV light which is reflected by the first mirror, a third mirror (206, 306, or 406) which is arranged to receive and reflect the EUV light which is reflected by the second mirror, and a fourth mirror (208, 308, or 408) which is arranged to receive and reflect the EUV light which is reflected by the third mirror.

FIG. 1

100

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**B. FIELDS SEARCHED**

Minimum documentation searched (classification system followed by classification symbols)

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Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Korean utility models and applications for utility models

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eKOMPASS(KIPO internal) &amp; Keywords: EUV, mask, mirror, concave, convex, inspection

**C. DOCUMENTS CONSIDERED TO BE RELEVANT**

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X A	US 2005-0201514 A1 (HANS-JURGEN MANN et al.) 15 September 2005 See abstract, pages 1-10 and claims 1-57.	1,4,6,8,18 2,3,5,7,9-17,19,20
A	US 2002-0017616 A1 (KAZUYA OTA) 14 February 2002 See abstract, pages 1-8 and claims 1-27.	1-20
A	US 6549270 B1 (KAZUYA OTA) 15 April 2003 See abstract, columns 1-20 and claims 1-87.	1-20
A	US 2009-0267003 A1 (MASATO MORIYA et al.) 29 October 2009 See abstract, pages 1-12 and claims 1-16.	1-20

 Further documents are listed in the continuation of Box C. See patent family annex.

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"&amp;" document member of the same patent family

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